

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	5	semiconductor adj wafer and exposure adj apparatus and eximer adj laser and reticle	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/07/26 13:15
S2	756779	vacuum	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 09:48
S3	0	(semiconductor adj wafer and exposure adj apparatus and eximer adj laser and reticle) and vacuum	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 09:48
S4	10	"5227862".URPN.	USPAT	OR	ON	2002/11/21 09:48
S5	9955	exposure adj apparatus	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:33
S6	466569	exposure	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 10:11
S7	666	vacuum adj stage	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 09:52
S8	109	exposure and (vacuum adj stage)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 09:55
S9	1069	eximer adj laser	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:34
S10	0	(exposure and (vacuum adj stage)) and (eximer adj laser)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 09:53

S11	0	(vacuum adj stage) and (eximer adj laser)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 09:56
S12	16894	reticle	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 09:57
S13	8977	exposure and reticle	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:34
S14	36	(eximer adj laser) and (exposure and reticle)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:24
S15	9955	exposure adj apparatus	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 16:50
S16	4	(vacuum adj stage) and (exposure adj apparatus)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 10:13
S17	2	("5286963").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2002/11/21 12:13
S18	27	"5286963".URPN.	USPAT	OR	ON	2002/11/21 12:13
S19	15	("4655599" "4962423" "5015866" "5137349" "5286963" "5323016" "5361122" "5448332" "5581324" "5635722" "5693439" "5742067" "5751428" "5781277" "5793471").PN.	USPAT	OR	ON	2002/11/21 12:29
S20	5	(eximer adj laser) and (exposure and reticle) and (ccd or "charge coupled device")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:32
S21	10	"5227862".URPN.	USPAT	OR	ON	2002/11/21 15:29

S22	955470	computer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:33
S23	1345	exposure adj apparatus and computer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:33
S24	509	exposure and reticle and (exposure adj apparatus and computer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:34
S25	3	eximer adj laser and (exposure and reticle and (exposure adj apparatus and computer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 15:35
S26	74	exposure adj apparatus and computer and "local area network"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2002/11/21 16:52
S27	1	("6451507").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2002/11/22 10:00
S28	2	("6330065").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2002/11/22 11:33
S29	211	(438/7).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2002/11/22 11:33
S30	3	((("6507388") or ("20030095241"))).PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2003/10/23 15:03

S31	10	("4011403" "4326805" "4749278" "4778275" "5877505" "5963616" "6018413" "6160622" "6268904" "6411368").PN.	USPAT	OR	ON	2003/10/23 15:01
S32	0	"6507388".URPN.	USPAT	OR	ON	2003/10/23 15:03
S33	1312	exposure adj apparatus and laser adj interferometer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2003/10/23 15:04
S34	71809	housing and (ambient or ambience)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2003/10/23 15:04
S35	29	(exposure adj apparatus and laser adj interferometer) and (housing and (ambient or ambience))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2003/10/24 09:43
S36	1	(exposure adj apparatus and laser adj interferometer) and (housing and (ambient or ambience)) and oxygen and ppm	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2003/10/24 09:43
S37	11	(exposure adj apparatus and laser adj interferometer) and (housing and (ambient or ambience)) and ppm	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2003/10/24 09:45
S38	14	(laser adj interferometer) and (housing and (ambient or ambience)) and ppm	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2003/10/24 09:46
S39	8	exposure adj apparatus and oxygen adj absorption and nitrogen and helium and laser	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2003/10/24 10:00
S40	665	(438/795).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/04/29 08:14

S41	141	(438/551).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/04/29 08:15
S42	587	(438/448).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/04/29 08:16
S43	428	(438/401).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/04/29 08:17
S44	68	(438/378).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/04/29 08:18
S45	262	(438/5).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/04/29 08:18
S46	362	(438/5).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/26 13:51
S47	372	(438/7).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/26 14:16
S48	0	(laser adj interferometer and housing and reflector and (reflector or reflecting or reflect) and exposure adj apparatus).clm.	US-PGPUB	OR	ON	2005/07/26 14:17